Electronic Acknowledgement Receipt FES ID: 1204224 Application Number: 10510695 Confirmation Number: 3939 METHOD OF MANUFACTURING SILICON SINGLE CRYSTAL. Title of Invention: SILICON SINGLE CRYSTAL AND SILICON WAFER First Named Inventor: Izumi Fusegawa Customer Number: 25944 Filer: Christopher W. Brown/Jori Krischke Filer Authorized By: Christopher W. Brown Attorney Docket Number: 121356 Receipt Date: 15-SEP-2006 Filing Date: 08-OCT-2004 Time Stamp: 18:13:14 Application Type: U.S. National Stage under 35 USC 371 International Application Number:

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Document Number	Document Description	File Name	File Size(Bytes)	Multi Part	Pages
1		121356Amendment9-15-06. pdf	399302	yes	10

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	Amendment - After Non-Final Rejection	1	1		
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If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

National Stage of an International Application under 35 U.S.C. 371

If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.